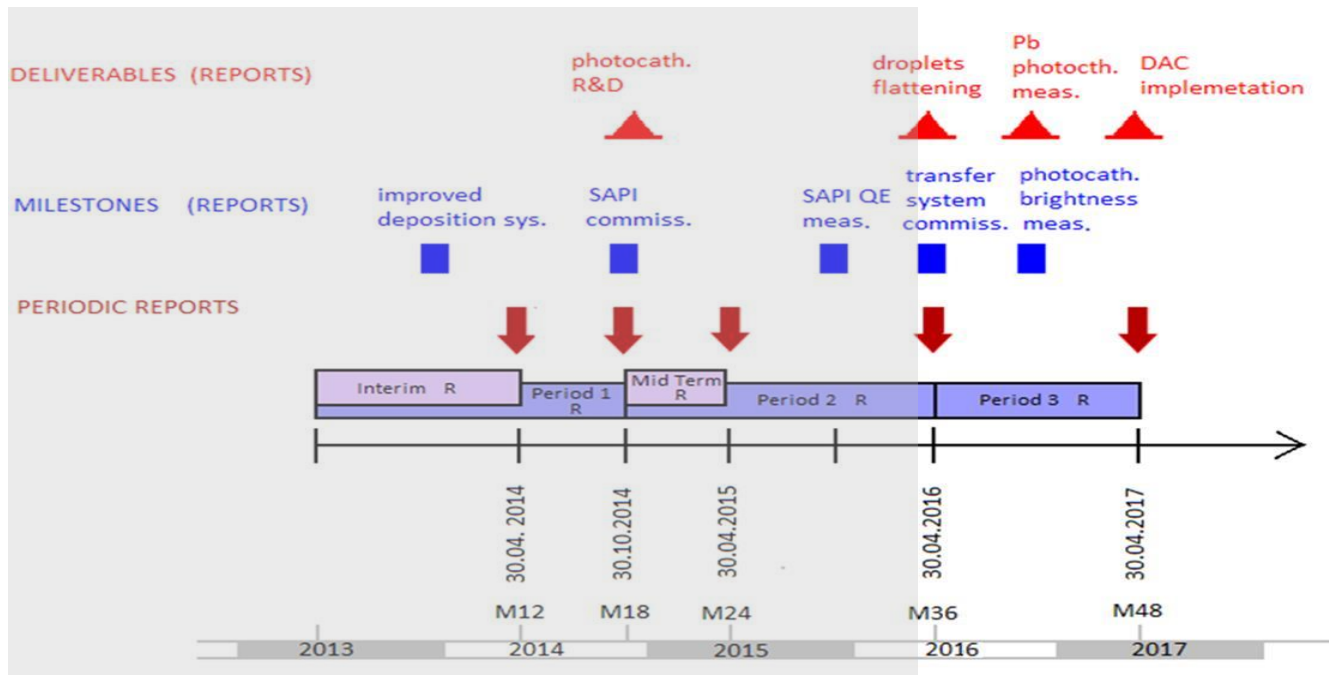


# Advances in thin film lead photocathodes

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## Milestones

Number	achievement	Performer	Deadline	Product
MS80	Demonstrated operation of improved deposition system, Pb layers of 1 $\mu\text{m}$ in thickness	NCBJ	M30	Report on sample characterisation
MS73	Commissioning of the SAPI for operation with metal photocathodes	STFC	M8	Publication report
MS75	Investigation of quantum yield and energy spectrum of the electrons, emitted from the metal photocathode surface in SAPI	STFC	M18	Intermediate scientific report
MS83	Manufacturing and commissioning of the photocathode transport system	STFC	M36	Technical design report
MS85	Investigation of the brightness of different metal photocathodes in a S-band NCRF gun	STFC	M42	Scientific report

## Deliverables

Number	achievement	Performer	Deadline	Product
D12.4	Scientific report on photocathode R&D	STFC	M18	Report
D12.8	Optimised procedure of preparation flat and adherent Pb/Nb layers	NCBJ	M36	Report
D12.9	Pb/Nb plug photocathodes measurements and characterization.	HZDR	M42	Report
D12.13	Results of DAC implementation in SRF guns.	HZB	M48	Report

Change the Deliverable

## **D. 12.8.**

Optimised procedure for microdroplets flattening with an UV laser



Optimised procedure for preparation of flat, clean and adherent Pb/Nb films

Reason

We found that plasma pulsed irradiation is more effective than the laser one. Basically we learned how thick layer must be deposited to undergo a right change caused by energy deposition.

Delay

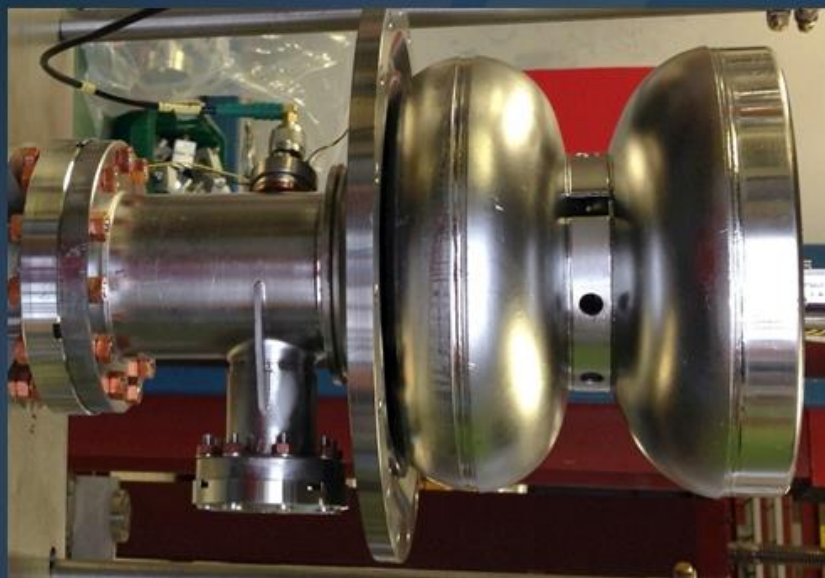
The all superconducting SRF-injector program at DESY is motivated by perspective of an increased flexibility in the time structure of the FLASH/EXFEL photon beams by enabling cw/lp operation.

## Present parameters of the DESY injector

	Unit	Spec 2014
Cathode	-	<u>Pb</u>
Bunch charge	<u>pC</u>	100-300
Bunch length	<u>ps</u>	3
Bunch rep. rate	kHz	100-33
Trans. slice emittance	$\mu\text{rad}$	< 0.7@100pC
Energy	MeV	3.7
Beam current	$\mu\text{A}$	10
QE	%	0.015@260nm
<b>Max. E on cathode</b>	MV/m	<b>40</b>
<u>E<sub>y</sub> on cathode</u>	$\mu\text{J}$	2.4-7.2
Laser P at cathode	W	0.24
Laser P at 1032	W	24

Challenging parameter is marked in yellow

The 1.5-cell gun cavity prototype was built at TJNAF. The present plug version has very effective cooling of the cathode.



1.5-cell , 1.3 GHz gun cavity



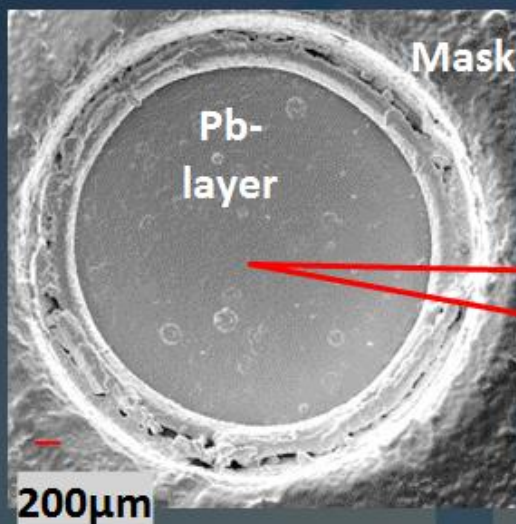
New plug with  
LHe channels



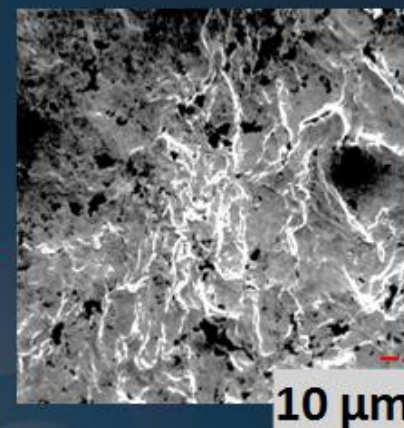
Nb/Pb  
cathode

## Roughness of the Pb coating (arc-deposition) on new plug

Courtesy NCBJ



Pb-layer after the plasma treatment  
Droplets  $\phi$  ca. 100 μm, elevation few μm

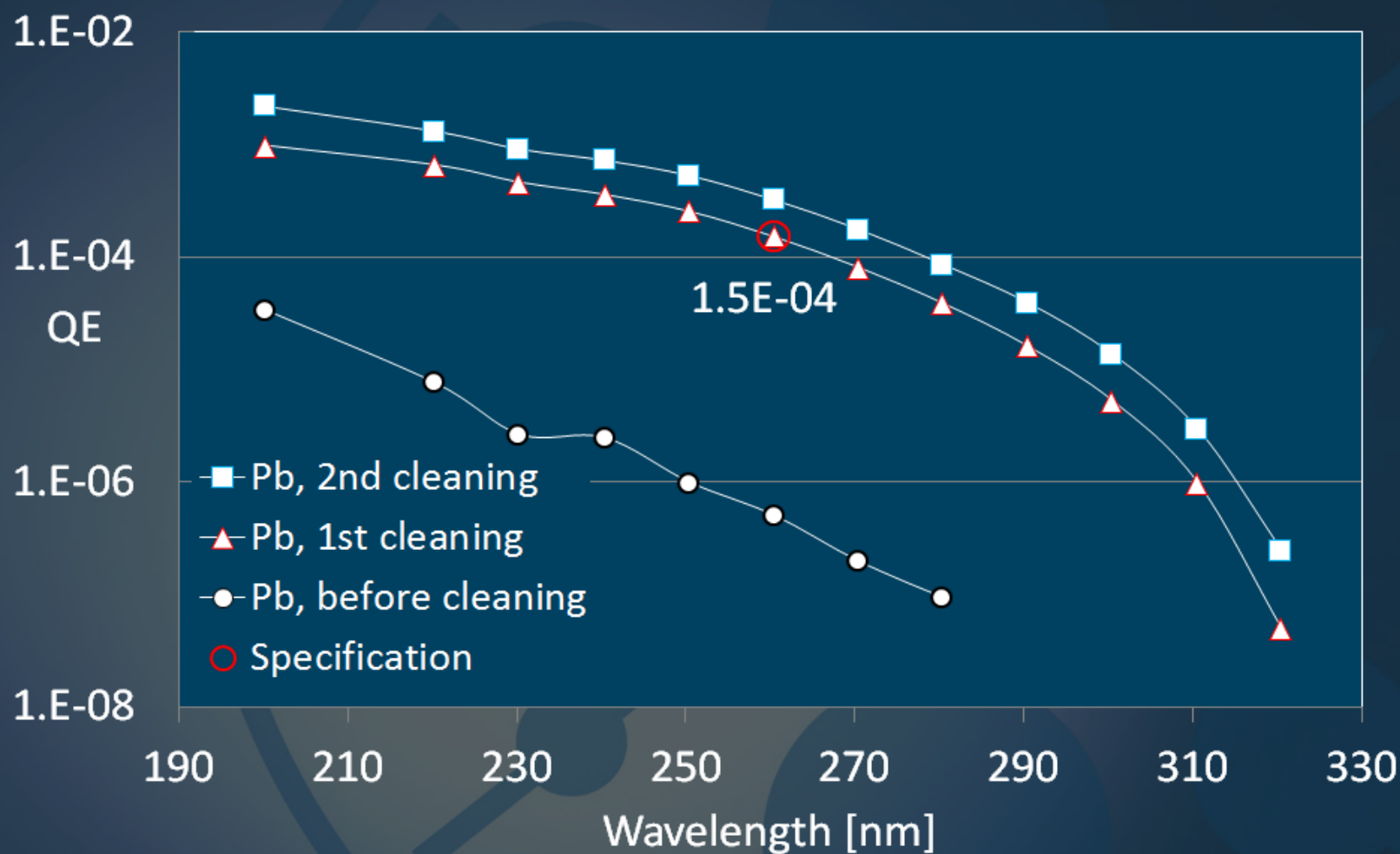


Courtesy BNL

Pb-layer after the 2<sup>nd</sup> laser cleaning

### Next

- Surface is too rough. Pb-layer is 15 μm thick. It will be molt by laser irradiation and then QE test will be repeated.
- The Pb-coated plug will be then installed in 1.5-cell at DESY for the SRF-test.

Recent QE test at BNL of the Pb coating on new plug

Courtesy J. Smedley, J. Sinsheimer,  
M. Gaowei and V. Gofron

Laser cleaning: 1<sup>st</sup> 1000 shots with 0.06 mJ/mm<sup>2</sup>,  
2<sup>nd</sup> 10000 shots with 0.06 mJ/mm<sup>2</sup>, all at 248nm

... towards *D12.9 Pb/Nb plug photocathodes measurements and characterization* at HZDR

The maximum program for the experiment would be:

1. assembling the Pb-coated plug in the vacuum chamber,
2. laser- cleaning accordingly to John's recipe,
3. measure QE at ca. 260 nm ,
4. irradiate the cathode for several weeks in total (can be done in many shorter periods) with your laser: 0,5 W, 500 kHz, 10 ps , 260 nm
5. measure QE again.

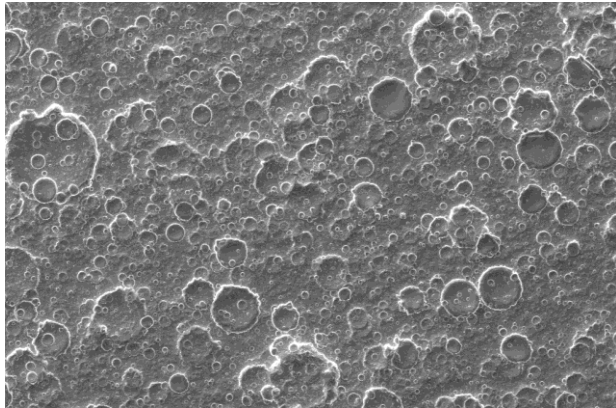


8  $\mu\text{m}$  Pb

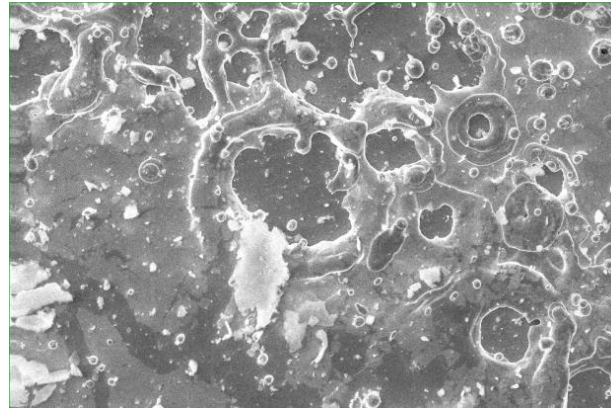
20  $\mu\text{m}$

X 500

X 1000



UHV arc deposition



1 plasma pulse of  $1.8 \text{ J/cm}^2$



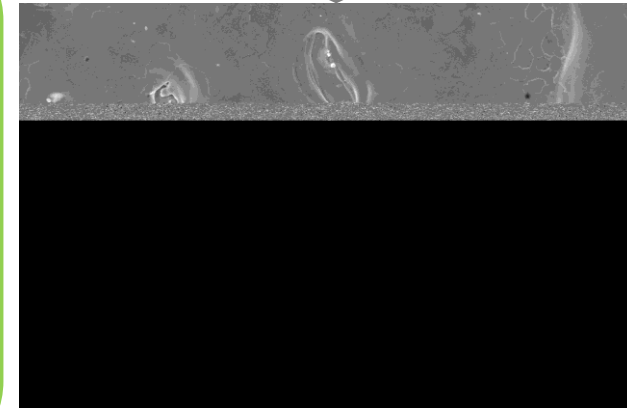
Too thin and thus perforated

- Distinct areas of perforations size of which did not exceed  $10 \mu\text{m}$
- non-coated area amounting to 3-5% of the total layer surface.



20  $\mu\text{m}$

X 2000



3 pulses of  $1.5 \text{ J/cm}^2$

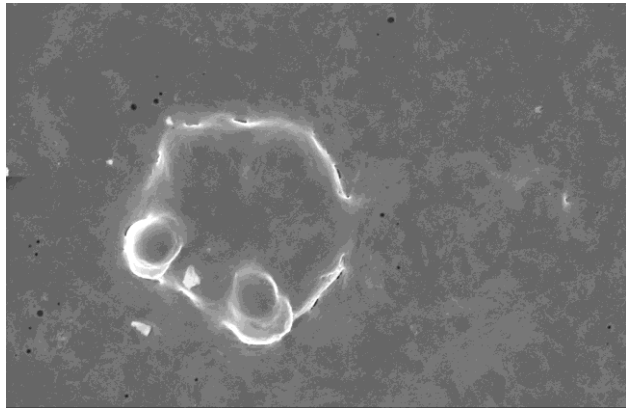
*15  $\mu\text{m}$  Pb underway...*

12  $\mu\text{m}$  Pb

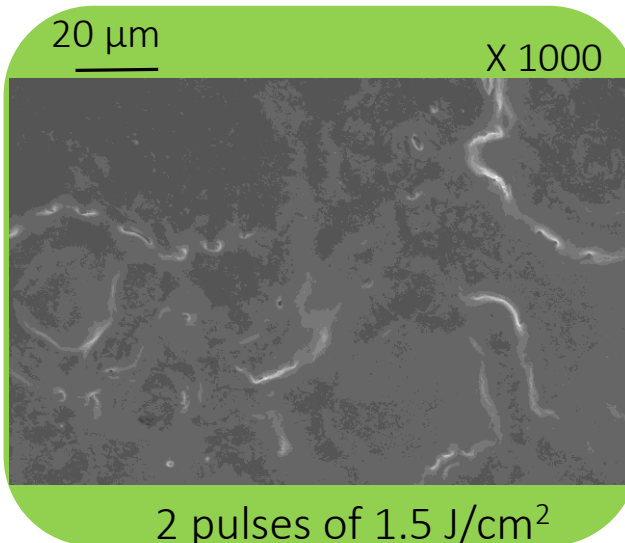
X 1000

20  $\mu\text{m}$

X 1000



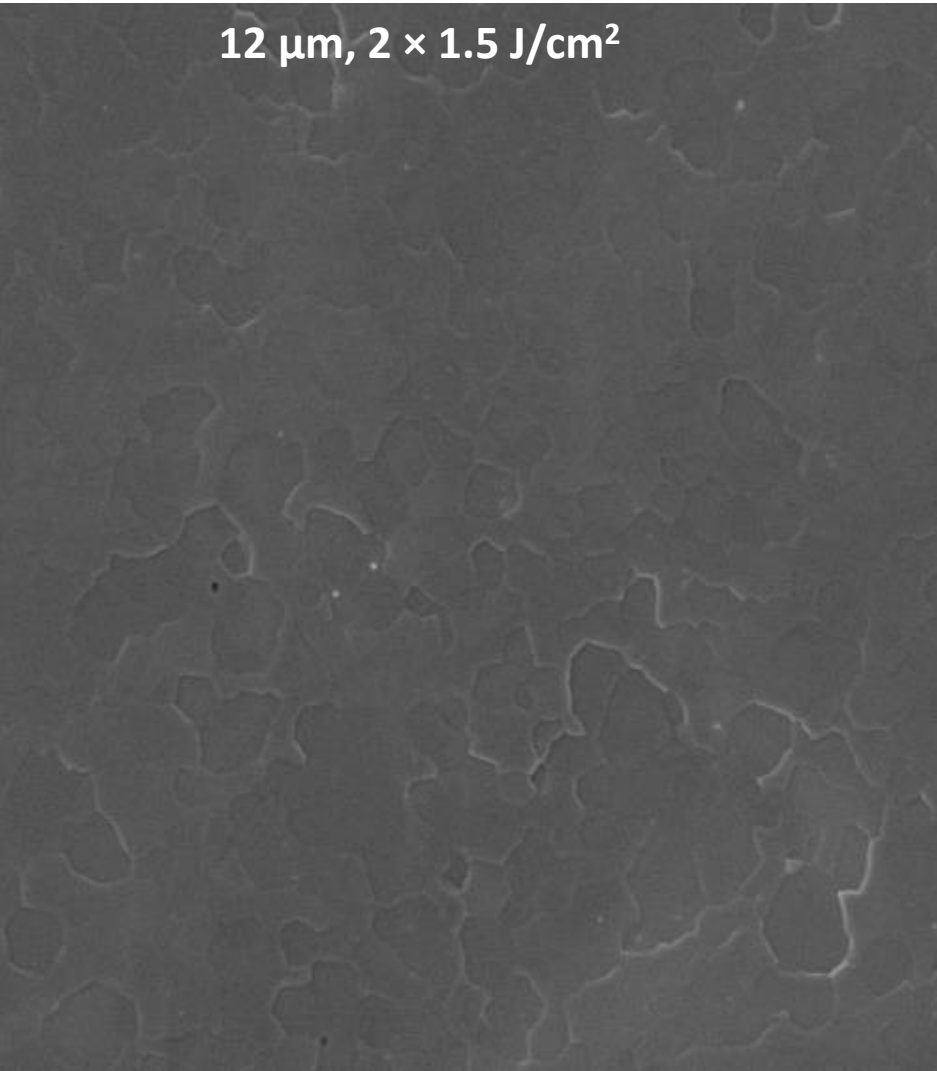
1 plasma pulse of  $1.5 \text{ J/cm}^2$



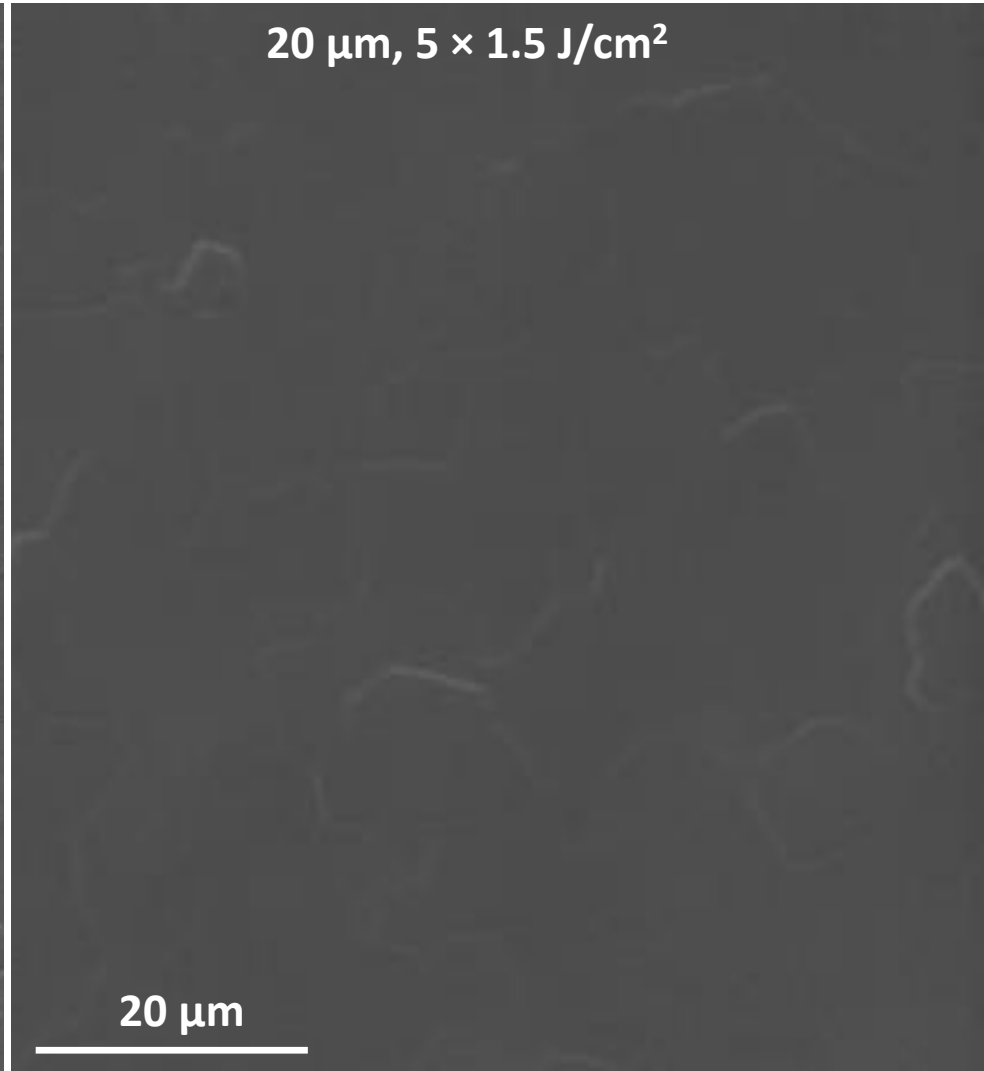
2 pulses of  $1.5 \text{ J/cm}^2$

# Further flattening

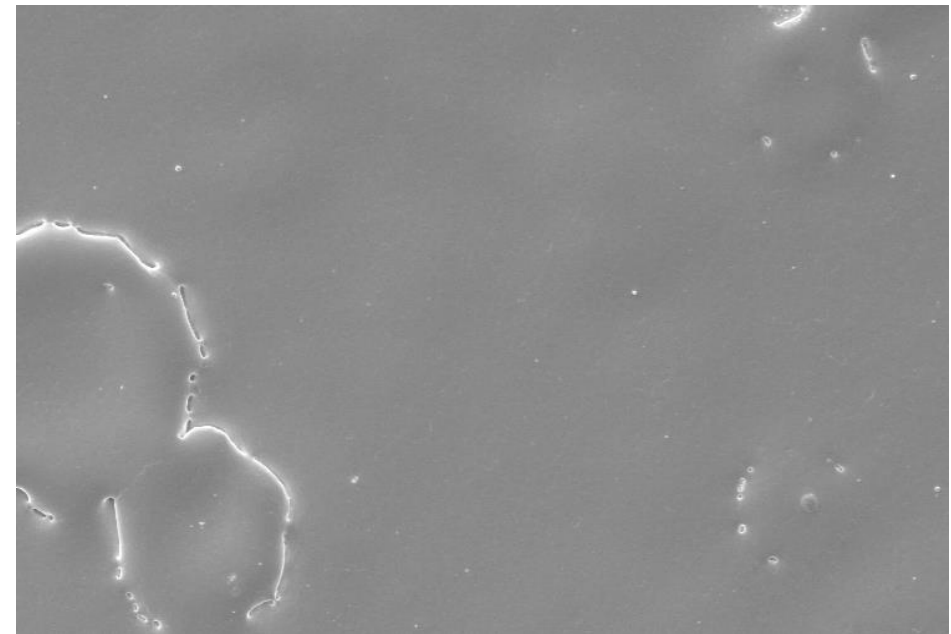
12  $\mu\text{m}$ ,  $2 \times 1.5 \text{ J/cm}^2$



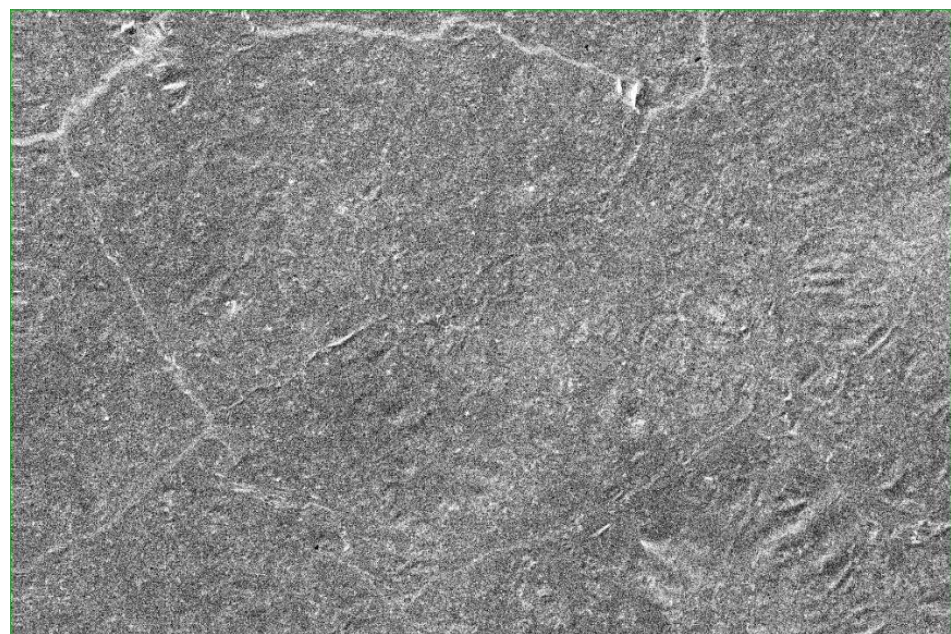
20  $\mu\text{m}$ ,  $5 \times 1.5 \text{ J/cm}^2$



# Further flattening

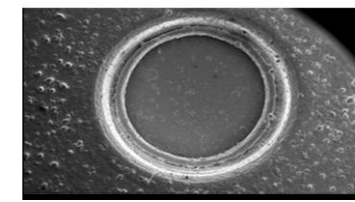


10  $\mu\text{m}$ ,  $25 \times 1 \text{ J/cm}^2$  through a hole in mask



10  $\mu\text{m}$ ,  $25 \times 1 \text{ J/cm}^2$  without shielding

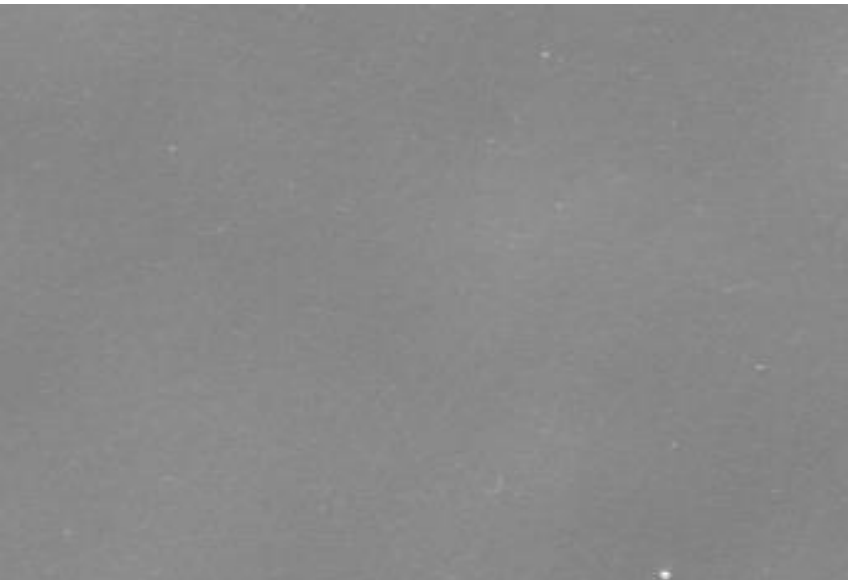
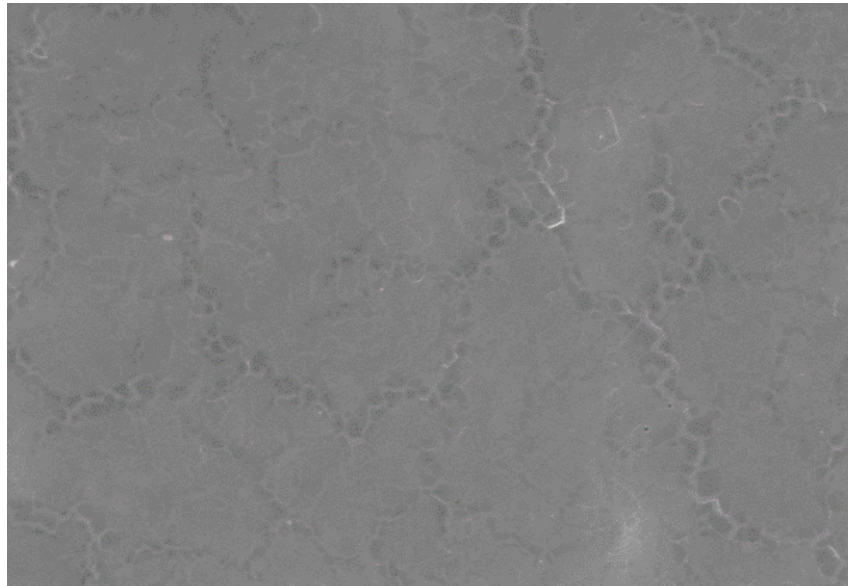
**50  $\mu\text{m}$**



**3 mm**

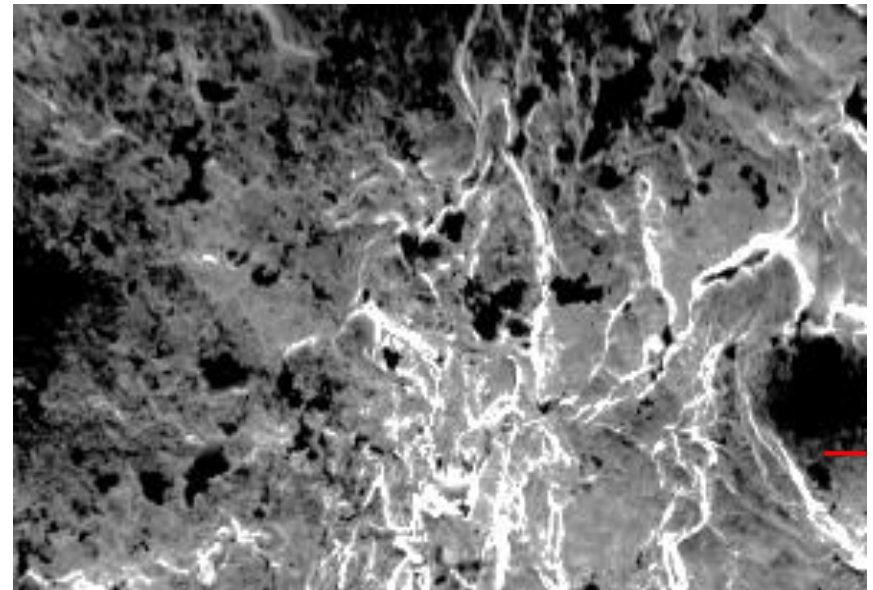
We found that surface morphology depends on that whether it was irradiated with a mask or without it. Mask impedes an energy transfer from pulse to layer. It leaves crater and droplets remnants

# Laser cleaning



**20 μm** 17 μm,  $5 \times 1.5 \text{ J/cm}^2$  through a hole in mask

Plasma irradiation leaves surface smooth Laser treatment increases the QE a lot. This is accompanied with the roughening the surface



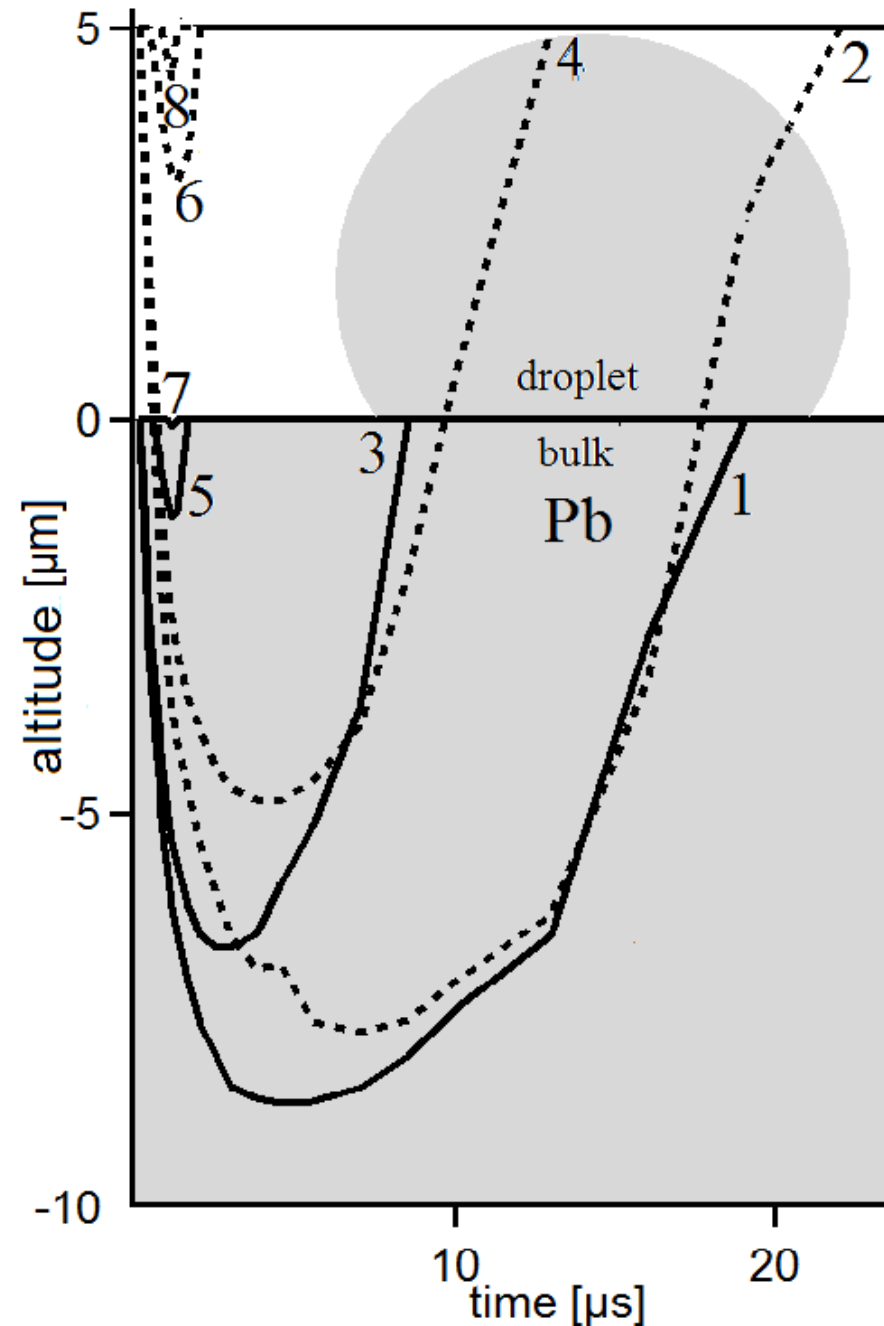
**20 μm**



# Calculations for 1 J/cm<sup>2</sup>

We managed to decrease the plasma pulse energy to get the fluency of 1 J/cm<sup>2</sup>. This reduces the samples thickness needed to survive. Corresponding heat transfer calculations have been performed

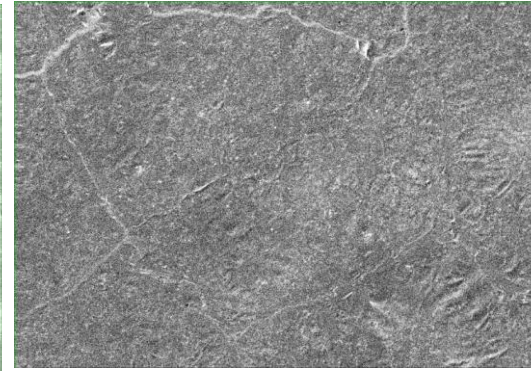
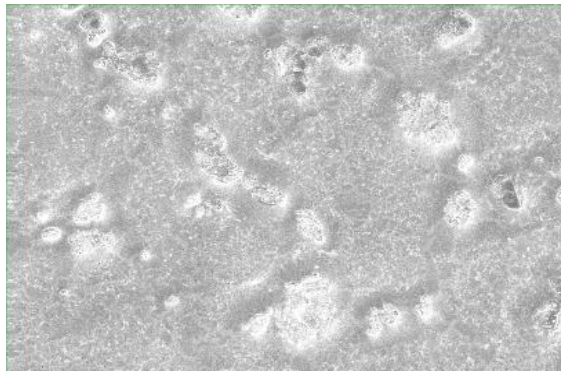
In depth propagation of melting and evaporation fronts. 1. – bulk melting, 1.5 J/cm<sup>2</sup>; 2. – droplets melting 1.5 J/cm<sup>2</sup>; 3. – bulk melting, 1 J/cm<sup>2</sup>; 4. – droplets melting 1 J/cm<sup>2</sup>; 5. – bulk evaporation, 1.5 J/cm<sup>2</sup>; 6. – droplets evaporation, 1.5 J/cm<sup>2</sup>; 7. – bulk evaporation, 1 J/cm<sup>2</sup>; 8. – droplets evaporation, 1 J/cm<sup>2</sup>



# X-ray diffraction

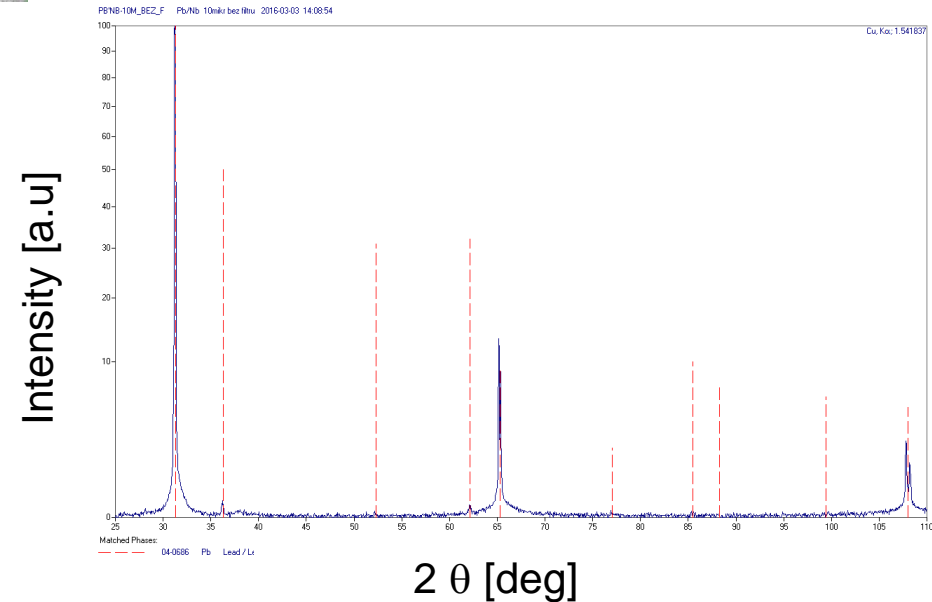
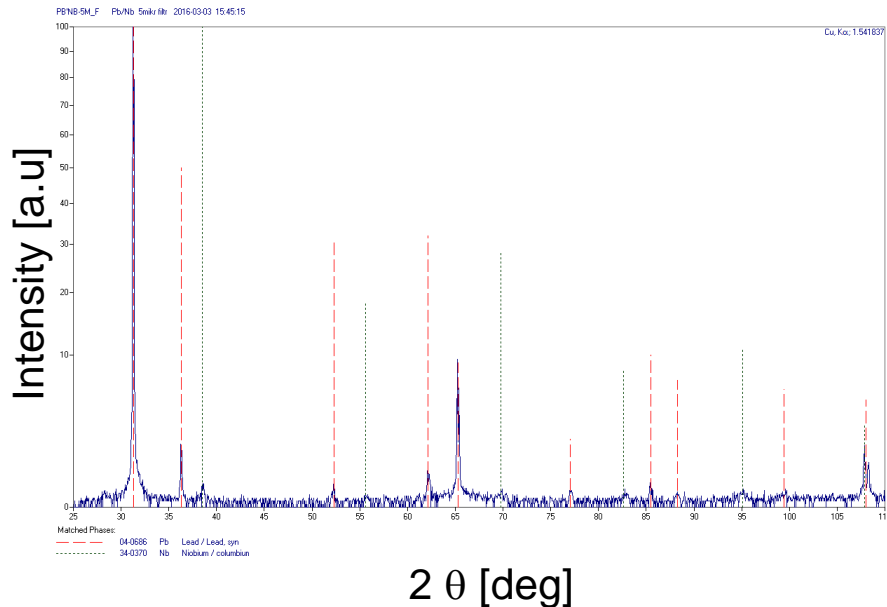
Measured with Cu  $K_{\alpha 1,2}$  with a laboratory diffractometer in  $\theta$ - $2\theta$  geometry

5  $\mu\text{m}$ ,  $10 \times 1 \text{ J/cm}^2$   
no shielding  
filtering



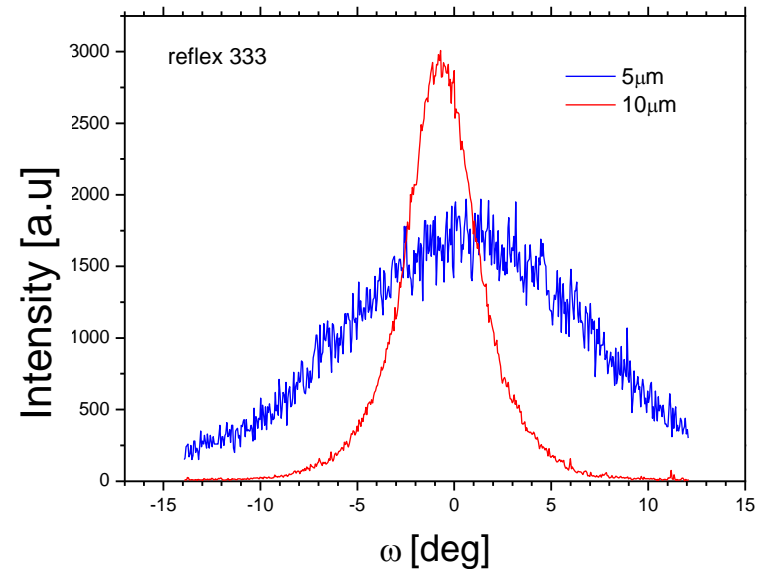
10  $\mu\text{m}$ ,  $25 \times 1 \text{ J/cm}^2$   
no shielding  
no filtering

**50  $\mu\text{m}$**

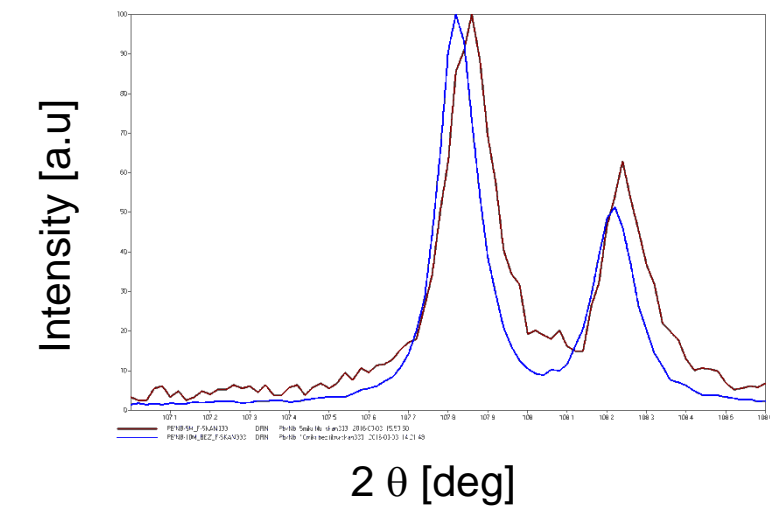


[111] texture occurs for both layers, for thicker layer however no other orientation can be seen.  
Does it come from thickness or from irradiation?  
Photoemission dependence on surface orientation will be studied by calculations

# X-ray diffraction



Rocking curve around reflex 333. It gives the distribution of [111] crystalline plane orientations relative to sample surface  
Spread of crystallite orientation in thocer layer is smaller



Fine scan of 333 reflections. Lattice constants and crystallites in-depth dimension [111] evaluated with Scherrer formula:

5 $\mu\text{m}$ filtered	$D_{111}=115\text{nm}$	$a= 4.9519 \text{ \AA}$
10 $\mu\text{m}$ unfiltered	$D_{111}=141\text{nm}$	$a=4.9529 \text{ \AA}$

# QE measurement setup

Xe lamp 150 W  $\Rightarrow$  0.5 W  
in 200 – 210 nm

Czerny-Terner  
monochromator,

Optical fiber

picoamperometer,  
measures above 10 pA

Nd:YAG laser, 2nd  
harmonic: 25 mJ/pulse,  
20 Hz, 10 ns

Turbo- and scroll- pumps  
give  $10^{-7}$  mbar





# QE measurement setup

Anode holder with an optical fiber and mirror

sample

Optical fiber

Faraday cup for breakdown

Sample holder rotates to enable laser cleaning

For breakdown measurements, the distance between sample and anode can be adjusted with accuracy of 0.25 mm  
HV pulse is 12.5 kV during 1ms  
⇒ 50 MV/m



## Measurements

We need

- 50 pA at 200 nm while QE- $10^{-5}$   $\rightarrow$  30  $\mu$ W of light on the sample
- 50 pA at 250 nm while QE- $10^{-6}$   $\rightarrow$  250  $\mu$ W of light on the sample

We measured 20 pA (10 pA above the noise) while using white light and dirty sample

Next Steps:

clean the sample with laser

or with glow discharge

improve the transmission, mostly mirror reflection

## Cleaning

- YAG harmonic 532 nm 5 mJ/ (mm<sup>2</sup>·pulse) , 10 Hz  $\Rightarrow$  0.05 W
- Excimer Kr 190 nm 10  $\mu$ J/ (mm<sup>2</sup>·pulse) , 300 Hz  $\Rightarrow$  0.003 W
- 240 nm, 60  $\mu$ J/(mm<sup>2</sup>·pulse),  $10^5$  pulses

2010

2015 (DESY& BNL)

Optimised procedure for preparation of flat, clean and adherent Pb/Nb films

Delay

We are going to produce a number of Pb/Nb samples

- flattened down to roughness  $< 1 \mu\text{m}$
- with QE measured higher than  $1.5 \cdot 10^{-4}$  at 260 nm

For that we need to prepare cleaning with excimer laser. Unfortunately it will not be possible this year, so we will try to substitute it with Nd:YAG 2nd harmonics and look for other cleaning methodes

We expect to be ready about November 2016

## Summary

- We reached the satisfactory flatness
- XRD studies
- QE measurements will be launched  
→ cleaning capabilities
- QE measurements vs laser irradiation time (DESY, HZDR)